

OXIDATION OF MOLYBDENUM BY LOW-ENERGY
OXYGEN-ION BOMBARDMENTOKSIDACIJA MOLIBDENA Z NIZKOENERGETSKIM KISI KOVIM
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We have studied the oxidation of pure molybdenum metal at room temperature (RT) by low-energy oxygen-ion bombardment within an analytical, ultrahigh vacuum chamber, using x-ray photoemission spectroscopy (XPS) around the Mo 3d core level. We provide a detailed characterization of the oxidation states of pure Mo and a comparison with the Mo oxidation in the CoCrMo alloy. After the thermal oxidation of pure metal at RT up to 5000 L of oxygen, the Mo 3d photoelectron remained almost unchanged. On the other hand, Mo oxidizes quite easily within the CoCrMo alloy by thermal oxidation at RT. The XPS spectra recorded after the ion bombardment showed a complex structure consisting of Mo⁴⁺, Mo⁵⁺ and Mo⁶⁺ oxidation states. Our study shows that pure Mo metal oxidizes more efficiently under oxygen-ion bombardment or when incorporated into the CoCrMo alloy. We explain our results in terms of the implantation dynamics of oxygen ions and the enhanced mobility and reactivity of oxygen atoms in the alloy, compared to the pure Mo metal.

Keywords: molybdenum, CoCrMo alloy, ion-beam oxidation, thermal oxidation, x-ray photoelectron spectroscopy

Z rentgensko fotoemisijnsko spektroskopijo (angl. XPS) smo preučevali oksidacijo čiste kovine molibdena (Mo) pri sobni temperaturi (angl. RT) z obstreljevanjem z nizkoenergetskim ionskim žarkom kisika znotraj komore z ultravisokim vakuumom. V študiji smo predstavili podrobno karakterizacijo oksidacije čiste kovine Mo in jo primerjali z oksidacijo Mo v CoCrMo zlitini. Po termični oksidaciji Mo v čisti kovini pri sobni temperaturi z odmerki kisika do 5000 L, fotoemisijnski spekter Mo 3d lupinskega nivoja ostane skoraj nespremenjen. Nasprotno temu, Mo oksidira z lahkoto v CoCrMo zlitini s postopkom termične oksidacije pri sobni temperaturi. Po drugi strani pa so XPS-spektri, posneti po ionskem obstreljevanju, pokazali kompleksno strukturo, ki jo sestavljajo oksidacijska stanja Mo⁴⁺, Mo⁵⁺ ter Mo⁶⁺. Naša študija kaže, da čisti Mo oksidira bolj učinkovito, če je obstreljevan z ioni kisika ali če je vključen v CoCrMo zlitino. Naše rezultate lahko interpretiramo v smislu implementacijske dinamike kisikovih ionov ter večje mobilnosti in reaktivnosti kisikovih atomov v zlitini, v primerjavi s čisto kovino Mo.

Ključne besede: molibden, CoCrMo zlitina, oksidacija z ionskim žarkom, termična oksidacija, rentgenska fotoemisijnska spektroskopija

1 INTRODUCTION

The CoCrMo alloy is currently one of the most important materials for biomedical applications due to its superior wear resistance, hardness and high corrosion resistance. It is frequently used for metal-on-metal hip resurfacing joints.¹ The possible release of metal ions due to corrosion is thought to have adverse effects on the surrounding body tissue and ultimately leads to the failure of the implant. The release of the metallic ions into the body tissue can be prevented by the formation of a thin oxide layer on the surface of the implant.² Thus, it is important to fully understand the oxidation mechanism of the CoCrMo alloy, which seems to be quite complex³ and requires a knowledge of the oxidation mechanisms of each metallic component. In the present paper we focus on the oxidation behaviour of molybdenum.

An additional motivation to study the oxidation of molybdenum is related to the variety of applications of molybdenum oxide films, such as heterogeneous chemistry and catalysis, microelectronics and nanotechnol-

ogy.^{4,5} Molybdenum oxides are important catalysts or catalyst precursors exhibiting catalytic properties in both selective oxidation and selective hydrogenation reactions.⁶ Also, both pure molybdenum oxides or mixtures with tungsten oxide are promising display materials due to changes of their colour reversibly upon light irradiation.⁷ Although molybdenum oxides are used in a variety of applications, the nature and catalytic properties of these materials are not yet fully understood. Since molybdenum has several oxidation states, ranging from +2 to +6, a variety of its oxide compounds may co-exist on the same surface. Therefore, any application of molybdenum oxides requires a detailed knowledge of the molybdenum oxidation states within the sample. Molybdenum oxide surfaces of varying chemical composition, complexity, crystallinity and intercalation have been extensively analyzed, especially with XPS.^{8–12} However, the interpretation of the results has not been consistent in the literature due to the complexity of the XPS spectra, particularly when samples include different oxidation states.¹³

It has been shown previously that the Mo surface is quite resistant to the thermal oxidation at temperatures below 300 °C.⁸ On the other hand, the ion-bombardment represents an efficient method for the oxidation of different metallic and semiconductor surfaces with controlled amount of oxidation and oxide thickness, even at room temperature.^{7–10} In our previous studies, we have shown that oxygen bombardment is more efficient in creating the oxide films on Ni and Co surfaces than oxidation by electrochemical methods or thermal oxidation.^{14,15}

In this paper we provide a detailed characterization of the RT oxidation of pure Mo metal by low-energy oxygen-ion bombardment or thermal oxidation in an oxygen atmosphere using X-ray photoelectron spectroscopy (XPS) and compare these results with the oxidation of Mo in the CoCrMo alloy.

2 EXPERIMENTAL PART

The Mo metal foil (M. Woite GmbH, 99.95 % of mass fractions of Mo) and CoCrMo alloy (58 % Co, 32 % Cr, 6 % Mo, 1.3 % Si) samples were first polished with SiC papers of 800–2500 grit and then washed with ethanol and redistilled water. Before any oxidation step, the Mo and CoCrMo surfaces were additionally cleaned within the analytical ultrahigh vacuum (UHV) chamber by cycles of low energy Ar⁺ bombardment at room temperature (these samples are referred to as cleaned samples). All the oxidation was conducted in situ in the main chamber of the XPS instrument with a broad beam of 500 eV O₂⁺ ions of the typical current density of 2 μA/cm². The thermal oxidation was performed by supplying the pure oxygen gas into the UHV chamber to a pressure of 6.5 × 10⁻⁴ Pa. In this case, the oxidation dose is expressed in units of Langmuir, defined as 1 L = 1.33 × 10⁻⁴ Pa.

Cleaned and oxidised Mo surfaces were characterized by XPS in a SPECS XPS spectrometer equipped with a Phoibos MCD 100 electron analyser and a monochromatized source of Al-K_α X-rays of 1486.74 eV. The typical pressure in the UHV chamber during the XPS analysis was in the 10⁻⁷ Pa range. For the electron pass energy of the hemispherical electron energy analyser of 10 eV used in the present study, the overall energy resolution was around 0.8 eV. The photoemission spectra were simulated with several sets of mixed Gaussian-Lorentzian functions with Shirley background subtraction using Unifit software.¹⁶

3 RESULTS AND DISCUSSION

The formation of different Mo-O bonds, related to the different oxidation states of the Mo, can be extracted from the chemical shifts in the photoemission spectra around the Mo 3d core-levels. We start with the thermal oxidation of Mo metal. In **Figure 1** we show several

characteristic Mo 3d photoemission spectra taken on the cleaned surface and surfaces oxidized with two different oxygen doses at RT. The cleaned sample shows a characteristic spin-orbit splitting of 3.1 eV of the Mo 3d level to Mo 3d_{3/2} and Mo 3d_{5/2}, at binding energies (BEs) of 231.2 and 228.1 eV, respectively. This doublet is assigned to the metallic state of Mo, Mo⁰, in good agreement with the data from the literature.^{8,9,11} After thermal oxidation at RT, shown in **Figure 1**, the Mo 3d photoemission remains almost unchanged up to the highest oxygen dose of 5000 L used in this study. This is in agreement with the previous studies of Mo oxidation, in which the thermal oxidation of Mo requires temperatures above 300 °C.⁸

On the other hand, bombardment with O₂⁺ ions leads to significant changes in the photoemission spectra, with the development of several new and well-defined peaks around the Mo 3d level. As an example, we show in **Figure 2** several Mo 3d spectra taken from a cleaned Mo surface and surfaces bombarded with 500 eV O₂⁺ ions for two different bombardment times of 5 min and 20 min, corresponding to the oxygen doses of 4.75 × 10¹⁵ O atoms/cm² and 1.5 × 10¹⁶ O atoms/cm², respectively. Obviously, the oxygen bombardment is more efficient for the formation of some new Mo bonds on the metal surface than the thermal oxidation.

The Mo 3d spectra of ion-bombarded surfaces show a quite complex structure. To identify the different components within that structure we fitted the experimental curves from **Figure 2** with the set of Voigt functions, as shown in **Figure 3**. We first note that the deconvolution

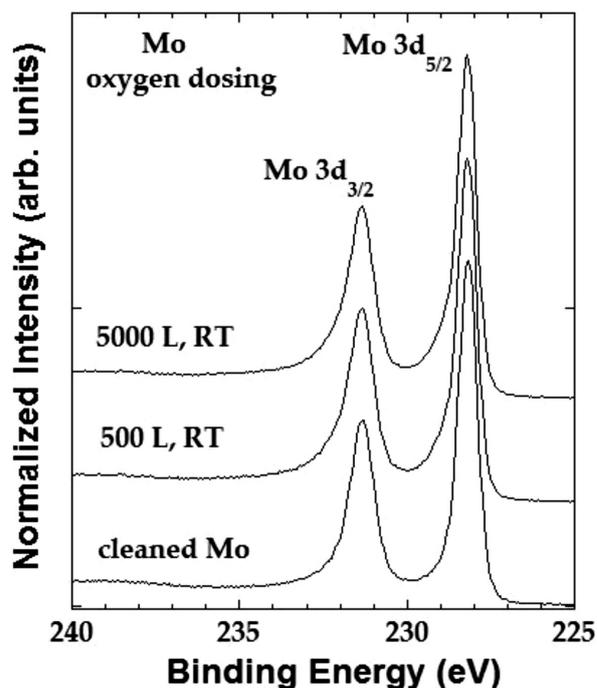


Figure 1: Mo 3d core-level photoemission spectra from a cleaned molybdenum surface and surfaces oxidized at room temperature (RT) with oxygen doses of 500 L and 5000 L

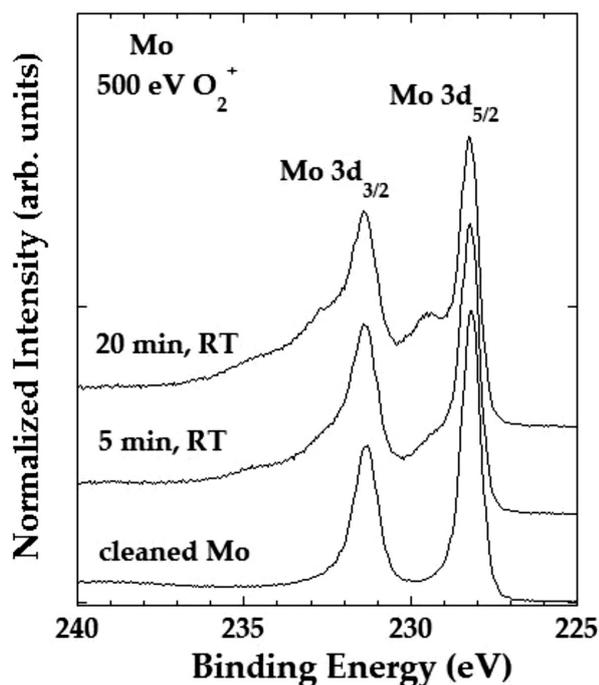


Figure 2: Mo 3d core-level photoemission spectra from a cleaned molybdenum surface and surfaces bombarded with 500 eV O_2^+ ions for 5 min and 20 min at room temperature (RT)

of the Mo 3d spectrum from the cleaned sample is dominated by the Mo $3d_{5/2}$ –Mo $3d_{3/2}$ doublet assigned to the Mo⁰ emission. However, a good fit of the experimental curve is obtained only by introducing two small additional doublets, with the main Mo $3d_{5/2}$ components

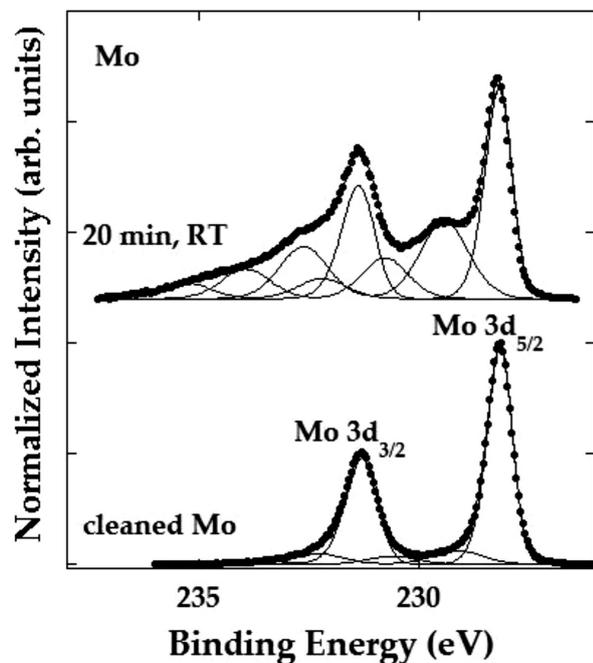


Figure 3: The deconvoluted Mo 3d spectra from a cleaned molybdenum sample and a sample exposed to 500 eV O_2^+ ions at RT for 20 min; solid lines represent product of Gaussians and Lorentzians, while closed circles represent experimental XPS spectra

at 229.4 eV and 230.7 eV, respectively. We assign these components to the intrinsic oxygen, most likely in the form of MoO₂ or Mo₂O₅, present in the Mo foil that has not been removed with our cleaning procedure.

Deconvolution of the spectrum from a sample bombarded to a high ion fluence of 1.5×10^{16} O atoms/cm² (i.e., for the 20-minute bombardment time, shown in **Figure 3**), exhibits three well-resolved doublets in addition to the Mo⁰ doublet, with the dominant Mo $3d_{5/2}$ peaks at BEs of 229.4, 230.8 and 232.2 eV, respectively. We assign these additional components to the emission from MoO₂, Mo₂O₅ and MoO₃, respectively, i.e., from the Mo⁴⁺, Mo⁵⁺ and Mo⁶⁺ oxidation states of Mo, respectively, in good agreement with the data from the literature.^{8,9,11}

Turning now to the oxidation of the CoCrMo alloy shown in **Figure 4**, we first note that the Mo 3d XPS spectrum of the cleaned CoCrMo sample is almost identical to the spectrum from the cleaned Mo metal foil from **Figure 1**. Furthermore, the thermal oxidation of Mo at RT in the alloy is more efficient than the thermal oxidation of the pure metal at RT to the same dose of 5000 L, clearly showing the formation of MoO₂ (Mo⁴⁺ oxidation state), Mo₂O₅ (Mo⁵⁺ oxidation state) and MoO₃ (Mo⁶⁺ oxidation state). These oxidation states are represented in **Figure 4** by three fitting doublets, in addition to the Mo⁰ doublet. Finally, the ion-bombardment of CoCrMo shows the different oxide structure of Mo, compared to the metallic molybdenum. Now the contribution from the Mo⁶⁺ states dominates the spectrum, as indicated in **Figure 4** for the sample bombarded with 500 eV O_2^+ ions for 20 min. At the same time, the

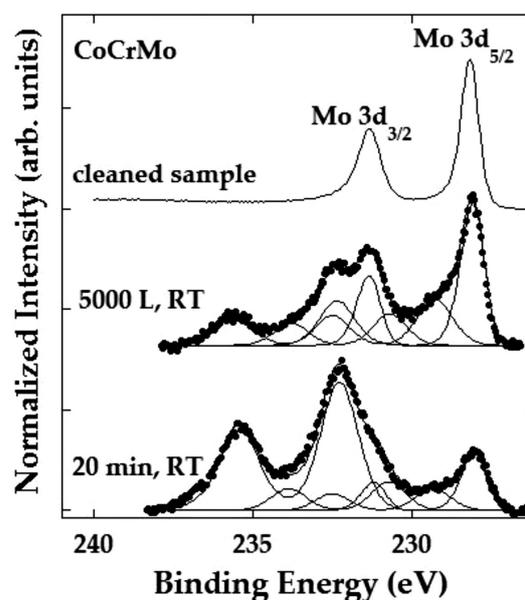


Figure 4: Comparison of Mo 3d core-level XPS spectra from a cleaned CoCrMo surface and surfaces oxidized at RT with 5000 L of oxygen or bombarded with 500 eV O_2^+ ions for 20 min (closed circles); the three fitting doublets of each spectrum (solid lines, representing product of Gaussians and Lorentzians) correspond to the emission from MoO₂, Mo₂O₅ and MoO₃

Mo⁰ component in the spectrum is greatly reduced. We stress here that the Mo⁰ peak is present in all ion-bombarded or thermally oxidised samples, indicating the formation of very thin oxide films on the surface. In such case, the XPS signal includes a contribution from the underlying metallic molybdenum.

The O 1s photoemission (not shown) was also recorded from all the oxidized surfaces. While the intensity of the oxygen peaks increases with the bombardment time or dose of oxygen, indicating the increase of oxygen concentration within the surface layer, the shape of O 1s peak does not show any significant changes. It is well known from the literature that the O 1s binding energies of many metal oxides fall within a very narrow range and it is not possible to separate the individual oxide contributions.¹⁷ The main O 1s peak, observed in our spectra around 530 eV, is usually assigned to all metal oxides, while the small shoulder, observed in our spectra around 531.5 eV, is assigned to the surface hydroxide groups or oxygen defects.^{18,19}

We conclude from the comparison of our results from **Figures 1 to 4** that the ion bombardment provides a more efficient oxidation process for molybdenum than the thermal oxidation, while Mo oxidizes more efficiently in the CoCrMo alloy compared to the pure Mo metal. We attribute this behaviour to the enhanced mobility and reactivity of oxygen atoms in the alloy, compared to the pure Mo metal. On the other hand, in contrast to thermal processes, the ion-induced oxidation eliminates the need for elevated temperatures and bypasses several thermally activated processes, such as absorption, dissociation, diffusion or bond breaking. The atomic collisions between the impinging oxygen and matrix atoms create different defects within the material, which are known to enhance the mobility and reactivity of oxygen anions and metal cations.^{20–23} Our measurements of ion-bombarded samples show, indeed, the effects expected from the radiation-enhanced oxidation, as observed previously for some other metals and semiconductors.^{15,20,21,23}

4 CONCLUSION

The thermal oxidation of Mo in pure Mo metal is not efficient at RT. However, Mo oxidises quite easily at RT within the CoCrMo alloy, showing characteristic contributions from the Mo⁴⁺, Mo⁵⁺ and Mo⁶⁺ oxidation states. The presence of Co and Cr reduces the surface barrier and enables a more efficient intake of oxygen within the sample.

On the other hand, the ion-induced oxidation of Mo is quite efficient at RT in both the Mo metal and the CoCrMo alloy. It is explained by the radiation-enhanced oxidation of Mo, as observed previously for some other metals and semiconductors. Again, contributions from the Mo⁴⁺, Mo⁵⁺ and Mo⁶⁺ oxidation states are present in all the oxides with the dominant contribution from the Mo⁶⁺ oxidation states for the high implantation doses of

oxygen. Finally, the RT ion-induced oxidation of Mo is more efficient than thermal oxidation in both the CoCrMo alloy and the pure Mo metal samples.

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